

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

IN RE APPLICATION OF: Ki-Ho Baik et al.

OCT 25 2007 SERIAL NO.: 10/817,140

RCE FILED: October 25, 2007

FOR: METHOD OF IMPROVING THE UNIFORMITY OF A
PATTERNEDE RESIST ON A PHOTOMASK

§ GROUP ART UNIT: 1756

§ (Parent Application)

§

§ EXAMINER: B. L. Raymond

§ (Parent Application)

§

§ Attorney Docket No.:

§ AM-8893 Y1

Date: October 25, 2007

PRELIMINARY AMENDMENT "C"

Mail Stop RCE
Hon. Commissioner for Patents
P.O. Box 1450
Alexandria, Virginia 22313-1450

Sir:

The present Preliminary Amendment "C" accompanies an RCE which is being filed on this date, October 25, 2007, in response to a Final Rejection mailed July 25, 2007 in the parent application. Applicants filed a Response "B" on October 9, 2007, in view of the Final Rejection. Subsequently, applicants' attorney was granted a telephone interview with the Examiner on October 15, 2007. On October 23, 2007, the Examiner contacted applicants' attorney to indicate that the application was not considered to be in condition for allowance. Claims 1 - 17 are pending in the application.

CERTIFICATE OF MAILING UNDER 37 CFR § 1.10

I hereby certify that this paper is being deposited with the U.S. Postal Service on the date shown below with sufficient postage as U.S. EXPRESS MAIL NO. EB 450583835 US in an envelope addressed to: Mail Stop RCE, Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450.

Date: October 25, 2007
Shirley L. Church, Reg. No. 31,858

Claims 1 - 17 are rejected under 35 U.S.C. § 103 (a) as being unpatentable over Kirkpatrick (U.S. Patent Application 2006/0084229 in view of Itoh (U.S. Patent Application 2004/0058279).

Please amend the application as follows.